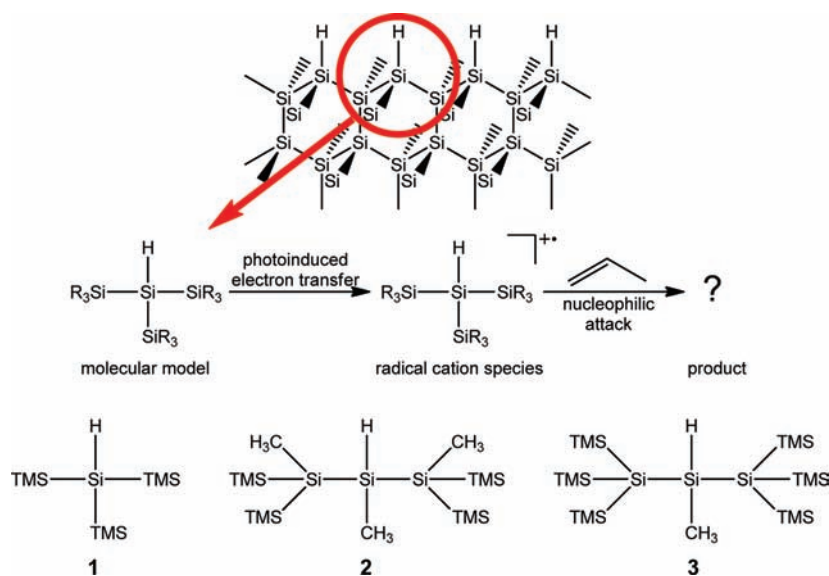


## Mimicking the Silicon Surface: Reactivity of Silyl Radical Cations toward Nucleophiles [Journal of the American Chemical Society 2011, 133, 4998–5008 DOI: 10.1021/ja110844e].

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Page 4999, Figure 2. Structures 2 and 3 are depicted as having a vertically oriented trimethylsilyl group at the central Si–H unit. However, this should be a methyl moiety, as indicated throughout the rest of the text. The corrected Figure 2 is shown here.



**Figure 2.** Representation of the selection of the models used in the current study (1–3) and the subsequent study of the silyl radical cations. Note: TMS =  $Si(CH_3)_3$ .

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